

CH₃O Yield in the CH₃ + O₃ Reaction Using the LP/LIF Technique at Room Temperature

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CH₃O(X²E) radicals have been detected by laser-induced fluorescence (LIF) for the first time as a product of the reaction between CH₃ and O₃. CH₃ radicals were generated by excimer-laser photolysis of CH₃Br at 193 nm in the presence of O₃ at room temperature and 100 Torr of He. The rate constant for reaction 1a (CH₃ + O₃ → CH₃O + O₂) has been determined by monitoring the CH₃O build-up as a function of reaction time and k_{1a} was found to be $(9.68 \pm 1.10) \times 10^{-14} \text{ cm}^3 \text{ molecule}^{-1} \text{ s}^{-1}$. The rate coefficient of the global reaction 1 (CH₃ + O₃ → products) has been determined by the numerical analysis of the CH₃O temporal profiles, yielding a value of $k_1 = (2.2 \pm 0.3) \times 10^{-12} \text{ cm}^3 \text{ molecule}^{-1} \text{ s}^{-1}$. Reaction of CH₃ with NO₂ has also been studied under the same experimental conditions as reaction 1 and has been used to calibrate the CH₃O LIF signal. On the other hand, the rate constant k_2 for reaction 2 (CH₃O + O₃ → products) has been directly determined ($k_2(T = 298 \text{ K}) = (2.53 \pm 0.75) \times 10^{-14} \text{ cm}^3 \text{ molecule}^{-1} \text{ s}^{-1}$) using the CH₃ONO($\lambda = 193 \text{ nm}$)/O₃/He system and was included in the chemical model used to describe the kinetics of CH₃ in the presence of O₃. The branching ratio $\phi_{\text{CH}_3\text{O}} = k_{1a}/k_1$ obtained was found to be (0.044 ± 0.013) . This low yield of CH₃O in reaction 1a can be explained not only by the formation of highly vibrationally excited CH₃O and the subsequent prompt dissociation to produce CH₂O + H but also by the direct formation of CH₂O + HO₂ in reaction 1.

1. Introduction

Despite the relevance of methyl radical, CH₃, in atmospheric chemistry, since this radical is produced in the earth's atmosphere by CH₄ oxidation, the nature of the products of the reaction of CH₃ with ozone, O₃,



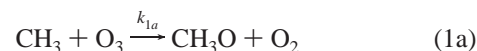
is still a matter of speculation. The kinetics of reaction 1 has been the subject of several direct^{1,2} and indirect studies.³ Simonaitis and Heicklen³ performed a kinetic study of reaction 1 by measuring the quantum yield of O₃ removal as a function of the O₃/O₂ ratio at +25 and -52 °C and at a pressure of about 1 atm. These authors photolyzed O₃ at $\lambda = 253.7 \text{ nm}$ in the presence of CH₄ and O₂. The chemical complexity of that system and the treatment of the proposed mechanism gave only an estimation of the rate constant of the above reaction. On the other hand, an upper limit for the rate constant of the reaction of CH₃O radical with O₃ in the same chemical system (O₃($\lambda = 253.7 \text{ nm}$)/CH₄/O₂)



was determined indirectly by Simonaitis and Heicklen.³ More recently, Washida et al.¹ carried out a room temperature study of the CH₃ + O₃ reaction at low pressures ($p_T = 2\text{--}6 \text{ Torr}$ of He), using a discharge-flow system coupled to a mass spectrometry detection system. The reaction of O atoms with C₂H₄ used to generate methyl radicals is thought to be more

complicated than was initially assumed. Finally, the last kinetic study of the CH₃ + O₃ reaction was also performed using low total pressures ($p_T = 2.2 \pm 0.2 \text{ Torr}$ in He) by Ogrzyzlo et al.² as a function of temperature ($T = 243\text{--}384 \text{ K}$). Laser photolysis of nitromethane, CH₃NO₂, at 193 nm was employed as a source of CH₃ radicals, and photoionization mass spectrometry was used to follow the CH₃ decay rate at various ozone concentrations.² Information regarding the products was not given in the above study, and the room temperature rate constant reported is approximately three times greater than those obtained in the two previous studies.

In the work described here, kinetic studies of CH₃ and CH₃O radicals with O₃ were carried out at room temperature and with a total pressure of 100 Torr in He. The experiments involved laser-pulsed photolysis (LP) of a suitable precursor to generate the transient species and laser-induced fluorescence (LIF) to monitor CH₃O(X²E) as a function of reaction time. A numerical simulation of the CH₃O concentration profiles was performed in order to derive k_1 . Furthermore, we report the first direct determination of the rate constant of the reaction CH₃O + O₃ (k_2) as well as the CH₃O yield in reaction 1 for the reaction channel,

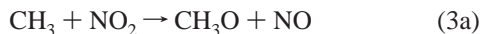


obtained by fitting the rate data to the simulated profiles and varying only the absolute rate constant for this route, k_{1a} , under the same experimental conditions.

Determinations of the rate constant k_{1a} and the branching ratio of CH₃O(X²E) formation in reaction 1, k_{1a}/k_1 , are achieved by comparing the time dependence of the CH₃O LIF signal with that recorded, under the same experimental conditions, in the reaction of CH₃ with NO₂, to calibrate the CH₃O LIF signal.

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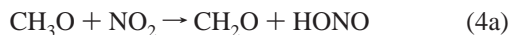
The reaction of CH₃ with NO₂ is known to proceed via two channels, a pressure independent channel,



and a pressure-dependent channel:



CH₃O radicals formed in reaction 3a react rapidly with NO₂ present in the reaction cell via the following processes:

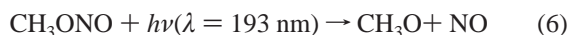
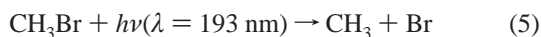


For this reason, kinetic data for both reactions 3 and 4 are required to analyze CH₃O temporal profiles obtained for the reference reaction. Analysis of the CH₃O temporal profiles yields the rate constant for the recombination reaction 3b as a function of total pressure ($p_T = 20\text{--}311$ Torr in He) at room temperature.

2. Experimental Section

All experiments were carried out using pulsed laser photolysis in combination with a pulsed laser-induced fluorescence technique (LP-LIF). Details of the experimental setup were previously described in recent publications regarding CH₃S^{4,5} and CH₃O⁶ radicals. A brief description of the experimental system and conditions is given below.

Photolysis of an appropriate precursor (commercial CH₃Br or synthesized CH₃ONO) using the pulsed 193-nm radiation of an ArF-excimer laser (OPTex, Lambda Physik), with fluences in the range 0.4–3 mJ pulse⁻¹ cm⁻², was used as a source of CH₃ and CH₃O radicals, respectively:



Because the CH₃ radical cannot be detected by LIF, the conversion of this radical into CH₃O in the presence of NO₂ or O₃ was used to monitor its kinetics in the reactions described here. A Nd:YAG-pumped frequency-doubled dye laser (Continuum ND60 and NY81CS-10) was used to monitor the CH₃O concentration decay or build up, generated either directly or indirectly, by exciting CH₃O radicals at $\lambda = 292.4$ nm:⁷



The resulting red-shifted fluorescence was subsequently collected at a right angle with respect to the excitation and photolysis beams in a photomultiplier tube (Thorn EMI, 9813B) coupled to the Pyrex reaction cell. A band-pass filter (Schott, BG5) or an interference filter centered at $\lambda = 360$ nm (Andover) was used to monitor the CH₃O LIF signal.

The kinetic studies of CH₃ and CH₃O radicals were carried out at room temperature under a total pressure of 100 Torr, and always under pseudo-first-order conditions with respect to the initial concentration of the radical generated in the photolysis. In the study of CH₃O formation by reaction 1a, the photolysis of CH₃Br ($[\text{CH}_3\text{Br}] = (1.9\text{--}9.8) \times 10^{14}$ molecule cm⁻³) generated CH₃ radicals ($[\text{CH}_3]_0 = (0.7\text{--}3.1) \times 10^{12}$ radical cm⁻³) in the presence of an excess of O₃ ($[\text{O}_3] = (0.5\text{--}5.8) \times 10^{14}$ molecule cm⁻³). The absorption cross section of CH₃Br at 193 nm used⁸ was 5.75×10^{-19} cm², and the quantum yield for CH₃ formation was taken to be unity.⁹ The CH₃O buildup

due to reaction 1a was also monitored by LIF. The same experimental conditions and concentrations were used in the study of the calibration process CH₃ + NO₂.

The diffusion of CH₃ and CH₃O radicals out of the detection zone constitutes only a minor channel at the experimental pressure used. However, this possibility was also considered:



In the kinetic study of the reaction CH₃O + O₃, the typical concentrations of the photochemical precursor used were $[\text{CH}_3\text{ONO}] = (0.35\text{--}2.14) \times 10^{15}$ molecule cm⁻³, giving $[\text{CH}_3\text{O}]_0 = (1.3\text{--}9.8) \times 10^{11}$ radical cm⁻³ ($\sigma_{\text{CH}_3\text{ONO}}(\lambda = 193 \text{ nm}) \sim 2 \times 10^{-18}$ cm²).¹⁰ The ozone concentrations employed in these experiments were in the range $(0.11\text{--}4.47) \times 10^{15}$ molecule cm⁻³.

Photolysis of O₃ present in the system at 193 nm ($\sigma_{\text{O}_3}(\lambda = 193 \text{ nm}) = 4.28 \times 10^{-19}$ cm²)¹¹ generates ground- and excited-state O atoms, O³P and O¹D, with quantum yields of 0.57 ± 0.14 and 0.46 ± 0.29 , respectively.¹² Typical total initial concentrations of atomic oxygen ($[\text{O}^3\text{P}] + [\text{O}^1\text{D}]$) were in the range $(0.053\text{--}4.00) \times 10^{12}$ atoms cm⁻³. The influence of these concentrations of atomic oxygen in the kinetic measurements is considered in the analysis of the results.

Reagents. Helium carrier gas (Carbueros Metálicos, 99.999%) was used without further purification. NO₂ and CH₃Br were taken from cylinders (Praxair, >99.5%) and were degassed by repeated distillation at low temperatures. The ArF gas mixture for the excimer laser was prepared by Praxair with the required specifications of Lambda Physik. Ozone was synthesized in a commercial ozonizer (Ozogas, TRCE-5000) and trapped in a liquid nitrogen trap, which was continuously pumped to remove any O₂ present and then was highly diluted in He (<1%). The exact O₃ concentration in the mixture was determined by its optical absorption at 253.7 nm in a 110 cm absorption cell located upstream of the photolysis reactor. This measurement was also used to derive the O₂ concentration present in the aged O₃ mixtures. Comparing the calculated $[\text{O}_3]$ in the mixture with the value determined by optical absorption, we estimated $[\text{O}_2] \cong 8 \times 10^{14}$ cm³ molecule⁻¹ s⁻¹ inside the reactor at the highest $[\text{O}_3] \cong 4 \times 10^{15}$ cm³ molecule⁻¹ s⁻¹. Usually $[\text{O}_2]$ was much less because $[\text{O}_3]$ was smaller and O₃ mixtures were freshly prepared frequently. Samples of CH₃ONO were freshly prepared by the dropwise addition of a 50% H₂SO₄/water solution to a 50% methanol/water solution that was saturated with NaNO₂. The reaction vessel was cooled in an ice bath, and the resultant gaseous product was dried by passage through Na₂CO₃ and molecular sieves. The gas was then collected at -50 °C. The CH₃ONO contained in the trap was transferred to a vacuum line and thoroughly purified by freeze-pump-thaw cycles and then highly diluted (0.6–1%).

3. Results

The results obtained in this work are described in three separate sections: CH₃ + NO₂ calibration reaction, CH₃O + O₃ reaction, and CH₃ + O₃ reaction.

3.1. Kinetics of the CH₃ + NO₂ Reaction: CH₃O Calibration. Figure 1 shows two examples of the CH₃O temporal profiles generated by photolysis of CH₃Br at 193 nm in the presence of different concentrations of NO₂ at $T = 298$ K and

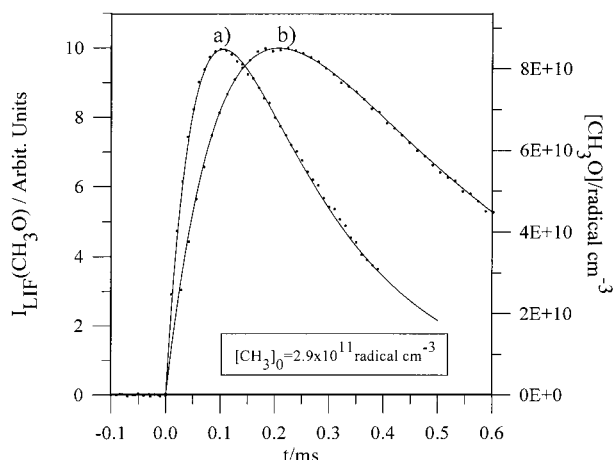


Figure 1. CH₃O temporal profiles obtained in the 193 nm photolysis of [CH₃Br] = 1.2 × 10¹⁴ molecule cm⁻³ at 298 K and 100 Torr, in the presence of (a) [NO₂] = 3.3 × 10¹⁴ and (b) 1.6 × 10¹⁴ molecule cm⁻³.

TABLE 1: Reaction Mechanism Used in the Numerical Simulation of the CH₃Br(λ = 193 nm)/NO₂/He System at T = 298 K and p_T = 100 Torr

reaction	k (cm ³ molecule ⁻¹ s ⁻¹)	reference
CH ₃ + NO ₂ → CH ₃ O + NO	k _{3a} = 2.5 · 10 ⁻¹¹	14
CH ₃ + NO ₂ + He → products + He	k _{3b} = variable	this work
CH ₃ O + NO ₂ → CH ₂ O + HONO	k _{4a} = 2 · 10 ⁻¹³	13
CH ₃ O + NO ₂ + He → CH ₃ ONO ₂ + He	k _{4b} = 1.41 · 10 ⁻¹¹	6
CH ₃ → diffusion	k _{diff} = 50 ^a	this work
CH ₃ O → diffusion	k _{diff} = 50 ^a	6

^a First-order rate coefficients, in inverse seconds.

100 Torr. Solid lines represent CH₃O concentration profiles numerically simulated using the FACSIMILE computer program. Variation of the NO₂ concentration is seen to influence the time at which the maximum occurs in the CH₃O signal.

The reaction mechanism and the rate constants employed in the simulation of the experimental CH₃O temporal profiles are given in Table 1. With the exception of k_{3b}, all the rate constants were fixed during the simulation process. The diffusional loss rate for the CH₃ radical is taken to be equal to that of CH₃O radical, with a value of k_{diff} = 50 s⁻¹ determined in our laboratory.⁶ The rate constant of the disproportionation reaction CH₃O + NO₂, i.e., k_{4a}, was fixed to the value extracted at T = 298 K from the expression obtained by McCaulley et al.¹³

$$k_{4a}(T) = 1.1 \times 10^{-11} \exp((-1200 \pm 600) K/T) \text{ cm}^3 \text{ molecule}^{-1} \text{ s}^{-1} \quad (\text{I})$$

As far as the association reaction rate constant, k_{4b}, is concerned, the value fixed at room temperature corresponds to that obtained in our recent work on the CH₃O + NO₂ reaction: k_{4b} = (1.41 ± 0.05) × 10⁻¹¹ cm³ molecule⁻¹ s⁻¹.⁶ The rate constant for CH₃O formation in the CH₃ + NO₂ reaction (k_{3a}) was fixed to the value determined by Yamada et al.¹⁴ The rate constant for the CH₃ + NO₂ recombination reaction (k_{3b}) was then varied to obtain the best fit of the simulated CH₃O concentration profiles to the experimental data. This technique allows a more accurate determination of the rate constant k_{3b} than does the simultaneous variation of k_{3b} and k_{4b}. The average rate constants k_{3b} extracted from the numerical analysis of the curves at T = 298 K and at different total pressures (p_T = 20–311 Torr) are listed in Table 2. The uncertainties quoted in these

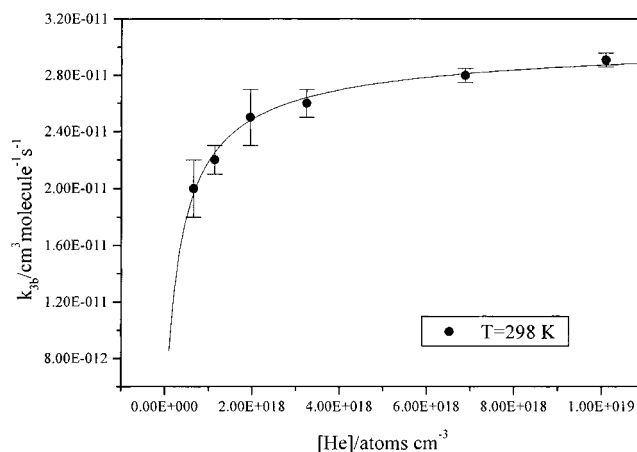


Figure 2. Falloff curve for the rate constant of the CH₃ + NO₂ + He recombination reaction at room temperature and p_T = 20–311 Torr.

TABLE 2: Summary of the Absolute Rate Constants of the CH₃ + NO₂ + He Reaction Obtained in the Fitting of the Experimental CH₃O Temporal Profiles at T = 298 K and Different Total Pressures

p _T (Torr)	[He] (10 ¹⁸ atoms cm ⁻³)	k _{3b} ± 2σ (10 ⁻¹¹ cm ³ molecule ⁻¹ s ⁻¹)
20	0.65	(2.00 ± 0.20)
35	1.13	(2.20 ± 0.10)
60	1.94	(2.50 ± 0.20)
100	3.24	(2.60 ± 0.10)
212	6.87	(2.80 ± 0.05)
311	10.08	(2.91 ± 0.05)

values are twice the standard deviation (±2σ). These rate constants for the CH₃ + NO₂ recombination reaction were fitted to a conventional Troe expression:¹⁵

$$k_{3b}(\text{He}) = \frac{k_{3b}^0[\text{He}]}{1 + (k_{3b}^0[\text{He}]/k_{3b}^\infty)} F_C^{\{1 + (N^{-1}(\log(k_{3b}^0[\text{He}]/k_{3b}^\infty)))^2\}^{-1}} \quad (\text{II})$$

$$N = 0.75 - 1.27 \log F_C \quad (\text{III})$$

where F_C is the broadening factor and k_{3b}⁰ and k_{3b}[∞] are the low- and high-pressure limiting rate constants, respectively, at a given temperature. The value of F_C is fixed at 0.6, as recommended by the JPL for atmospheric reactions.¹⁶ The falloff curve generated in the nonlinear least-squares fitting to eq II of rate constants k_{3b} obtained in this work is presented in Figure 2. The values of k_{3b}⁰ and k_{3b}[∞] extracted from this analysis are

$$k_{3b}^0(T = 298 \text{ K}) = (3.73 \pm 0.72) \times 10^{-28} \text{ cm}^6 \text{ molecule}^{-2} \text{ s}^{-1}$$

$$k_{3b}^\infty(T = 298 \text{ K}) = (3.26 \pm 0.40) \times 10^{-11} \text{ cm}^3 \text{ molecule}^{-1} \text{ s}^{-1}$$

where the error limits include ±2σ and estimated systematic errors in the determination of concentrations.

The numerically simulated CH₃O concentration profiles were fitted with FACSIMILE to the time-dependent LIF(CH₃O) signals obtained under the same conditions. This process allows a relationship to be established between LIF intensity and [CH₃O], and this can be used in the study of the CH₃ + O₃ reaction (see Section 3.3).

3.2. Kinetic Study of the CH₃O + O₃ Reaction. Photolysis of CH₃ONO at λ = 193 nm was used as a source of CH₃O in

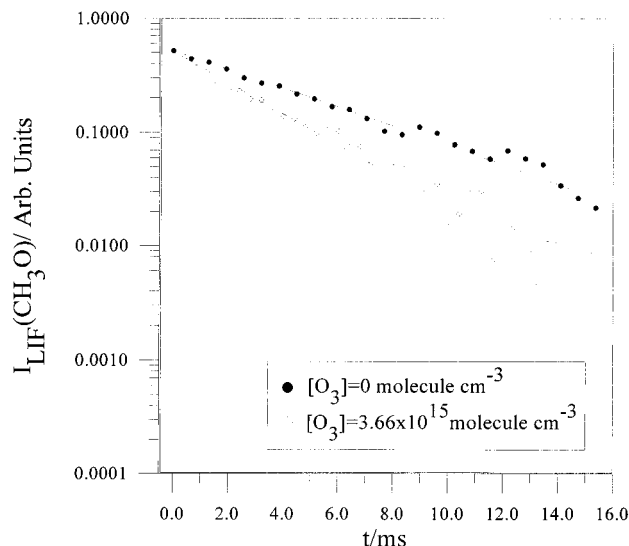
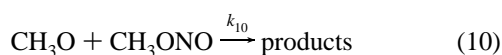


Figure 3. Semilogarithmic plots of CH₃O LIF signal obtained in the photolysis of [CH₃ONO] = 2.1 × 10¹⁴ molecule cm⁻³ at λ = 193 nm in the absence (○) and in the presence of [O₃] = 3.66 × 10¹⁵ molecule cm⁻³ (●).

order to study the kinetics of this radical both in the absence and in the presence of different ozone concentrations at 100 Torr of pressure. The CH₃O LIF temporal profiles recorded are monoexponential in all cases, as can be seen in the example of the semilogarithmic plots presented in Figure 3. The pseudo-first-order rate coefficients, *k'*, obtained from the analysis of these temporal profiles are 191 and 315 s⁻¹ in the absence and presence of O₃, respectively.

In the absence of reactant, a set of experiments was carried out using different precursor concentrations. In these experiments, the kinetics of CH₃O is mainly determined by diffusion (reaction 9) and reaction with its photochemical precursor, CH₃-ONO:



A pseudo-first-order plot for reaction 10 is shown in Figure 4a. The slope of this linear representation gives rise to the following:

$$k_{10}(T = 298 \text{ K}) = (4.45 \pm 0.90) \times 10^{-13} \text{ cm}^3 \text{ molecule}^{-1} \text{ s}^{-1}$$

Similar experiments were carried out under pseudo-first-order conditions in the presence of different O₃ concentrations. Figure 4b shows an example of the linear pseudo-first-order plots obtained. The rate coefficient determined from the slope of this plot for CH₃O + O₃ reaction was *k*₂(*T* = 298 K) = (3.25 ± 0.64) × 10⁻¹⁴ cm³ molecule⁻¹ s⁻¹. The mean value obtained for this reaction is

$$k_2(T = 298 \text{ K}) = (2.53 \pm 0.75) \times 10^{-14} \text{ cm}^3 \text{ molecule}^{-1} \text{ s}^{-1}$$

The mean value of *k*₂ obtained in the CH₃ONO/O₃/He system was then used in the chemical model described in the next section. This model was used to determine the rate constant of CH₃O formation in reaction 1a for the CH₃Br/O₃/He system.

3.3. Kinetics of the CH₃ + O₃ Reaction: CH₃O Yield. The rate of CH₃O formation in reaction 1a was studied under pseudo-first-order conditions with respect to the initial concentration

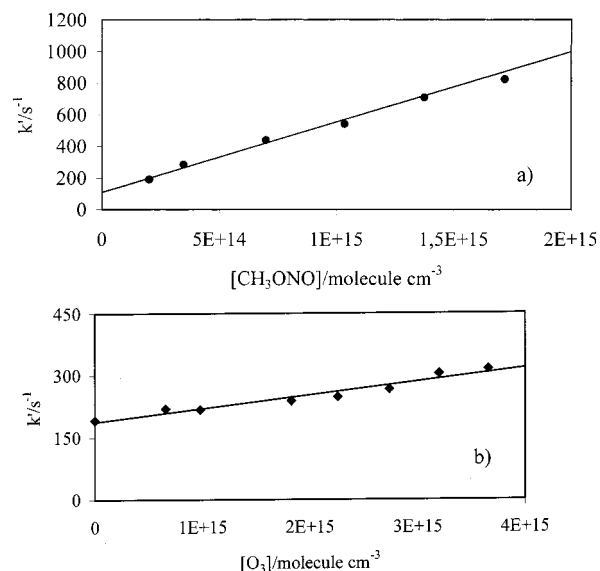


Figure 4. Pseudo-first-order plots obtained at *p*_T = 100 Torr and room temperature (a) in the absence of ozone and (b) in the presence of different [O₃] using a CH₃ONO concentration of 2.1 × 10¹⁴ molecule cm⁻³.

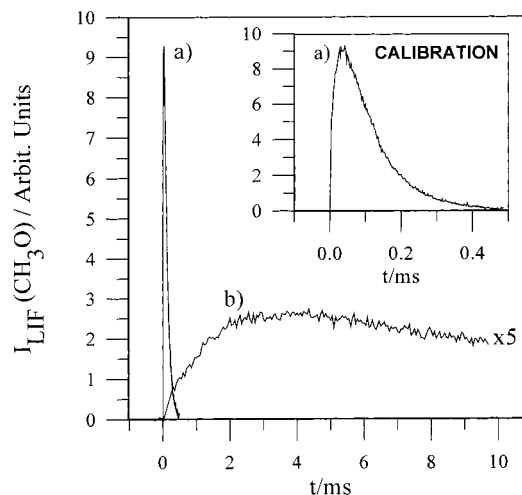


Figure 5. Comparison between time-dependent CH₃O profiles in (a) CH₃Br(λ = 193 nm)/NO₂/He calibration system, where [NO₂] = 3.6 × 10¹⁴ molecule cm⁻³ and (b) CH₃Br(λ = 193 nm)/O₃/He system, where [O₃] = 3.1 × 10¹⁴ molecule cm⁻³. Experimental conditions: [CH₃Br] = 1.92 × 10¹⁴ molecule cm⁻³ and [CH₃]₀ = 1.03 × 10¹² radical cm⁻³. The inset corresponds to the [CH₃O] profile presented in part a rescaled in 500 μs time.

of the CH₃ radical at room temperature and at a total pressure of 100 Torr. The difference in CH₃O concentrations formed in the calibration reaction (CH₃ + NO₂) and in the CH₃ + O₃ reaction is clearly demonstrated in Figure 5. In both cases, the same photochemical precursor (CH₃Br) was used and the same concentrations of CH₃ radical and reactant were employed. It can be seen, however, that the CH₃O signal observed for reaction 3a is about 20 times greater than that for reaction 1a. Thus, in Figure 5, the CH₃O fluorescence signal obtained in the reaction of CH₃ radicals with O₃ is multiplied by a factor of 5 in order that a better comparison can be made.

Numerical simulation of CH₃O concentration profiles was performed using the FACSIMILE computer program. This study involved different kinetic mechanisms in order to analyze the influence of different reactions on the values of *k*₁ and *k*_{1a} derived from the fitting of the calculated profiles to the LIF CH₃O signal.

TABLE 3: Reaction Scheme Used in the Analysis of the CH₃O Temporal Profiles Obtained at T = 298 K and 100 Torr in CH₃Br(λ = 193 nm)/O₃/He System

second-order reactions	k (298 K) (cm ⁻³ molecule ⁻¹ s ⁻¹)	reference
basic mechanism		
CH ₃ + O ₃ → CH ₃ O + O ₂	k _{1a} = variable	this work
CH ₃ + O ₃ → products	k ₁ = 2.2 × 10 ⁻¹²	this work
CH ₃ O + O ₃ → products	k ₂ = 2.53 × 10 ⁻¹⁴	this work
CH ₃ + CH ₃ → C ₂ H ₆	k ₁₁ = 8.0 × 10 ⁻¹¹	17
CH ₃ O + Br → products	k ₁₂ = 7 × 10 ⁻¹¹	18
CH ₃ → diffusion	k _{diff} = 50 ^a	this work
CH ₃ O → diffusion	k _{diff} = 50 ^a	6
Additional O Atom Reactions Included in the Extended Mechanism		
O(³ P) + CH ₃ O → products	2.5 × 10 ⁻¹¹	30
O(³ P) + CH ₃ → CH ₃ O	2.6 × 10 ⁻¹⁴	31
O(³ P) + CH ₃ → CH ₂ O + H	k ₁₆ = 1.1 × 10 ⁻¹⁰	32
O(¹ D) + CH ₃ Br → BrO + CH ₃	k ₁₃ = 7.78 × 10 ⁻¹¹	19, 20
O(¹ D) + CH ₃ Br → O(³ P) + CH ₃ Br	1.5 × 10 ⁻¹¹	19
O(¹ D) + O ₃ → 2O ₂	1.2 × 10 ⁻¹⁰	21
O(¹ D) + O ₃ → 2O + O ₂	1.2 × 10 ⁻¹⁰	21
Other Additional Reactions		
Br + O ₃ → BrO + O ₂	1.1 × 10 ⁻¹²	16
BrO + CH ₃ O → products	3.8 × 10 ⁻¹¹	18
CH ₃ O + CH ₃ → products	2.63 × 10 ⁻¹¹	33

^a First-order rate coefficients, in inverse seconds.

The most important reactions are included in the *basic mechanism* (see Table 3). This chemical model consists of reactions 1a, 1, and 2, together with CH₃ recombination, reaction of CH₃O with Br atoms, and diffusion of CH₃ and CH₃O out of the detection zone. For k₂, the value determined above in Section 3.2 of this work was used, whereas for the methyl radical recombination reaction,

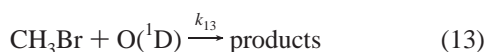


the value obtained by De Avillez et al.¹⁷ was used, because in most cases [CH₃]₀ was greater than 1 × 10¹² radical cm⁻³. However, the recombination reaction of CH₃O radicals was not included in this model, because the concentrations generated were low ([CH₃O]_{max} ≤ 5 × 10¹¹ radical cm⁻³) and were therefore influential to only a small extent. For the reaction



the rate coefficient determined by Aranda et al. was assumed.¹⁸

Although the excimer laser photolysis wavelength selected was 193 nm rather than 248 nm, to minimize O₃ dissociation, the reactions of oxygen atoms generated in the photolysis (O(³P) and O(¹D)) are considered in the *extended mechanism* presented in Table 3. As the experiments were performed in He, where the quenching of O(¹D) produced in the photolysis of ozone is slow, an additional source of CH₃ could arise from the rapid reaction of CH₃Br with O(¹D),¹⁹



where CH₃ is formed with a yield of 0.44 ± 0.05.²⁰ This reaction was also considered in the extended mechanism together with the reaction of O(¹D) with O₃²¹ and the quenching of excited O in the presence of CH₃Br.¹⁹

Additional secondary chemistry included in the extended mechanism (see Table 3) was the reactions of CH₃O with CH₃

and BrO,¹⁸ as well as the reaction of Br with O₃.¹⁶ Other bromine and crossed radical reactions considered showed a negligible influence on the determination of k₁ and k_{1a}.

The possible effect of the reaction of CH₃ with O₂,



on the determination of k₁ and k_{1a} was negligible at the O₂ concentrations present in our system, with the only oxygen arising from the presence of O₂ in the aged O₃ mixtures (see Experimental Section).

Initially, reaction 1 was considered to proceed only through reaction 1a to form CH₃O. In this case, varying the branching ratio, k_{1a}/k₁, would only affect the calculated absolute concentration of CH₃O but not the shape of the CH₃O profile from which the total rate coefficient k₁ was determined upon optimizing only this parameter in the simulation process.

The rate coefficients k₁ obtained with the extended mechanism differ by less than 5% from those obtained using the *basic mechanism* and both provide a good description of the experimental profiles. The mean value of k₁ obtained from the analysis of the experimental data is

$$k_1(T = 298 \text{ K}) = (2.2 \pm 0.3) \times 10^{-12} \text{ cm}^3 \text{ molecule}^{-1} \text{ s}^{-1}$$

The rate coefficients k₁ and k₂ determined in this work were included in the kinetic mechanisms considered. From this approach, we derived k_{1a} and the CH₃O yield by comparing the time dependencies of the CH₃O concentration profiles obtained by photolysis of CH₃Br/NO₂ and CH₃Br/O₃ under the same experimental conditions (concentration, pressure, temperature, flow conditions, and laser fluence). The relationship between I_{LIF} and [CH₃O] obtained in the kinetic study of the CH₃ + NO₂ reaction (Section 3.1) was used to calibrate the CH₃O LIF signal registered in the study of the CH₃ + O₃ reaction. In this calibration, the CH₃O LIF signal was transformed into CH₃O concentrations at different times, and the data were input into the FACSIMILE program in order to analyze the concentration–time profiles obtained. This analysis was performed using the kinetic mechanisms presented in Table 3 and by varying only the parameter k_{1a}. This numerical analysis allows the influence of several reactions to be determined in the CH₃O yield obtained in the CH₃ + O₃ reaction.

An example of these temporal profiles (dots) and the corresponding best fit using the extended mechanism (line) is shown in Figure 6. In this case, the value of k_{1a} extracted from the analysis is (9.91 ± 0.10) × 10⁻¹⁴ cm³ molecule⁻¹ s⁻¹. If only the basic mechanism is considered, the best fit of the experimental data gives k_{1a} = (9.47 ± 0.12) × 10⁻¹⁴ cm³ molecule⁻¹ s⁻¹, where the quoted ±2σ errors reflect only the precision of the fit.

In all cases, the fitting of the calculated profiles to the experimental data is reasonably good and is slightly better with the extended mechanism. The difference in the derived value of k_{1a} is less than 5% and is smaller than the estimated uncertainty associated with systematic errors in the determination of concentrations. Taking into account all the results and the estimated experimental errors, the average value derived for the rate constant of reaction 1a is

$$k_{1a} = (9.68 \pm 1.10) \times 10^{-14} \text{ cm}^3 \text{ molecule}^{-1} \text{ s}^{-1}$$

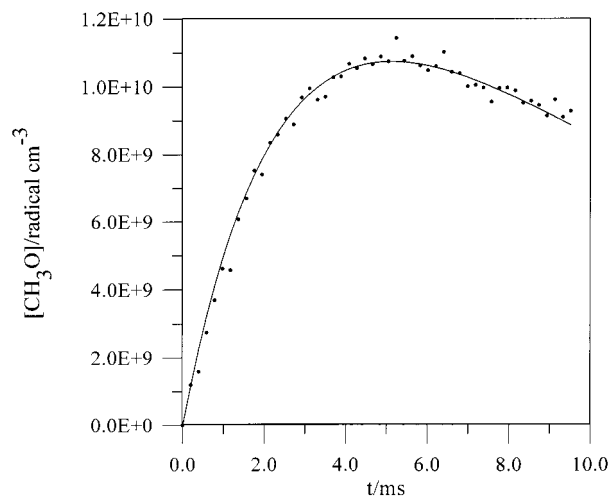


Figure 6. Numerical analysis of the CH₃O concentration profiles recorded in the reaction of $[\text{CH}_3]_0 = 7.8 \times 10^{11}$ radical cm^{-3} with ozone ($[\text{O}_3] = 1.1 \times 10^{14}$ molecule cm^{-3}) at $T = 298$ K. Several kinetic mechanisms are used in order to find the best fit of the curve (see text).

According to these results, the yield of the CH₃O formation channel in the reaction of CH₃ with O₃, $\phi_{\text{CH}_3\text{O}} = k_{1a}/k_1$, is

$$\phi_{\text{CH}_3\text{O}} = (0.044 \pm 0.013)$$

Thus, reaction 1a accounts for about 4.4% of the global CH₃ loss by reaction with O₃.

The influence of the different LIF quenching rates by O₃ and NO₂ was not determined precisely. Nevertheless, considering that both species are angular triatomic molecules of similar size and structure, and taking into account the recent study by Kukui et al.²² in which a maximum correction of about 10% was determined for the different rates of CH₃O fluorescence quenching by CH₃I and DMDS, we estimate that in the present study the correction should be smaller and is included in the uncertainty ranges given for $\phi_{\text{CH}_3\text{O}}$.

On the other hand, the estimated influence on the determination of the CH₃O yield of a 10% uncertainty in the initial $[\text{CH}_3]$ value is less than 8%, and the effect of the rate constants uncertainties used for reactions 1–4 is smaller than 3%.

4. Discussion

4.1. Kinetics of the CH₃ + NO₂ Reaction: CH₃O Calibration. The product of the recombination reaction 3b could be either CH₃ONO or CH₃NO₂. Yamada et al. did not observe CH₃NO₂ in the reaction CH₃ + NO₂.¹⁴ This fact is in sensible agreement with the small CH₃NO₂ yield (0.04–0.07) obtained by McCaulley et al. at low pressures (0.5–1 Torr).²³ Combining the rate constant determined by Yamada et al.¹⁴ for the bimolecular process (reaction 3a) with their data for the CH₃NO₂ yields, McCaulley et al.²³ estimated the low-pressure limiting rate constant k_{3b}^0 given in Table 4. It can be seen from the data in this table that the value of k_{3b}^0 obtained in this work is

$$k_{3b}^0(T = 298 \text{ K}) = (3.73 \pm 0.72) \times 10^{-28} \text{ cm}^6 \text{ molecule}^{-2} \text{ s}^{-1}$$

which is in fair agreement with that obtained by McCaulley et al.²³ as well as in other investigations.^{22,24,25} On the other hand,

TABLE 4: Comparison of the Low- and High-Pressure Limiting Rate Constant, k_{3b}^0 and k_{3b}^∞ for the CH₃ + NO₂ + He Association Reaction at Room Temperature

carrier gas	$(k_{3b}^0 \pm 2\sigma) \times 10^{28}$ ($\text{cm}^6 \text{ molecule}^{-2} \text{ s}^{-1}$)	$(k_{3b}^\infty \pm 2\sigma) \times 10^{11}$ ($\text{cm}^3 \text{ molecule}^{-2} \text{ s}^{-1}$)	reference
He	(2.73 ± 0.72)	(3.26 ± 0.40)	this work ^a
	(2.17 ± 1.20)	(3.45 ± 0.50)	this work ^b
	(4.2 ± 0.5)	(2.0 ± 1.0)	22
	(0.6 ± 0.2)		23
Ar	9.89	3.43	24
	(3.2 ± 1.3)	(4.3 ± 0.4)	25

^a $p_T = 20$ –311 Torr. ^b $p_T = 12$ –612 Torr (Composite Dataset).

the value obtained in this work for k_{3b}^∞

$$k_{3b}^\infty(T = 298 \text{ K}) = (3.26 \pm 0.40) \times 10^{-11} \text{ cm}^3 \text{ molecule}^{-1} \text{ s}^{-1}$$

is in good agreement, within the uncertainty ranges given, with those determined by Glänzer and Troe²⁴ using a shock-tube system at high temperatures in Ar ($T = 1100$ – 1400 K) and with recent LP/LIF studies performed at room temperature in He²² and as a function of temperature in Ar.²⁵ To compare the rate constants obtained in Ar with those obtained in He, the data in Ar have been assigned an equivalent pressure of He to reflect the relative third-body efficiencies of these bath gases ($\beta_C(\text{He}) = 0.07$ and $\beta_C(\text{Ar}) = 0.12$).²⁶

The strong pressure dependence of k_{3b} observed in this work was not evident in the kinetic study of reaction 3 made by Biggs et al. in a discharge-flow system.²⁷ These authors found k_3 to be independent of pressure between 1 and 7 Torr, with a rate constant of $(2.3 \pm 0.3) \times 10^{-11} \text{ cm}^3 \text{ molecule}^{-1} \text{ s}^{-1}$. This may reflect the fact that the measurements were not carried out over an extended pressure range, and that the effect at low pressures is partially disguised by the presence of the fast, pressure independent bimolecular reaction 3a.

If all data sets, which cover a pressure range of 12–612 Torr, are included in the fitting procedure, using Troe formalism, the low- and high-pressure limiting rate constants obtained are

$$k_{3b}^0(T = 298 \text{ K}) = (2.17 \pm 1.20) \times 10^{-28} \text{ cm}^6 \text{ molecule}^{-2} \text{ s}^{-1}$$

$$k_{3b}^\infty(T = 298 \text{ K}) = (3.45 \pm 0.50) \times 10^{-11} \text{ cm}^3 \text{ molecule}^{-1} \text{ s}^{-1}$$

The agreement of these results, within the error limits, with the values of k_{3b}^0 and k_{3b}^∞ extracted from the analysis of the rate constants listed in Table 2 denotes that both limiting rate constants are determined reasonably well using our data between 20 and 311 Torr. Error limits include $\pm 2\sigma$ and estimated systematic errors in the determination of concentrations. Nevertheless, the fit to the composite dataset must give more reliable values, especially for the low-pressure limit.

4.2. Kinetic Study of the CH₃O + O₃ Reaction. The only previous study of reaction 10 reported in the literature was performed in Ar at total pressures between 100 and 342 Torr using a shock wave system.²⁸ The CH₃O generated by thermal decomposition of CH₃ONO was monitored by chemiluminescence. The authors reported a value of $k_{10} = 4.15 \times 10^{-12} \text{ cm}^3 \text{ molecule}^{-1} \text{ s}^{-1}$ independent of temperature in the range 700–900 K. The value determined in this study is consistent with a weak temperature dependence of k_{10} .

On the other hand, as far as we know, the only previous value of k_2 reported in the literature is an upper limit, indirectly determined by Simonaitis and Heicklen.³ A value of $k_2 < 2 \times 10^{-15} \text{ cm}^3 \text{ molecule}^{-1} \text{ s}^{-1}$ was estimated at room temperature using the $\text{O}_3(\lambda = 253.7 \text{ nm})/\text{CH}_4/\text{O}_2$ chemical system. This value is 10 times lower than the value directly determined for the first time in the present study.

4.3. Kinetic Study of the $\text{CH}_3 + \text{O}_3$ Reaction: CH_3O Yield.

As stated in Results, the influence of the secondary chemistry, which was not included in the basic mechanism, for the determination of k_1 and k_{1a} from the kinetic data of CH_3O radicals was small (less than 5%) at the concentrations present in our system. Although a CH_3O yield was not determined in Cronkhite and Wine's work²⁰ on the reaction of $\text{CH}_3\text{Br} + \text{O}(\text{D})$, we considered the possibility of direct CH_3O formation in this reaction. However, such a mechanism is not consistent with the experimental CH_3O temporal profiles observed.

As mentioned in the Introduction, the kinetics of the $\text{CH}_3 + \text{O}_3$ reaction have been the subject of three previous studies.^{1–3} Simonaitis and Heicklen³ estimated the ratio of rate constants for reactions 1 and 14, obtaining values of $k_1/k_{14} = 1.17$ at -52°C and 2.17 at 25°C . Considering $k_{14} = 4.3 \times 10^{-13} \text{ cm}^3 \text{ molecule}^{-1} \text{ s}^{-1}$ at the high-pressure limit and assuming that this value is independent of temperature, they obtained the Arrhenius expression

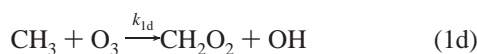
$$k_1(T) = 5.4 \times 10^{-12} \exp(-530/T) \text{ cm}^3 \text{ molecule}^{-1} \text{ s}^{-1} \quad (\text{IV})$$

yielding $k_1(T = 298 \text{ K}) = 9.1 \times 10^{-13} \text{ cm}^3 \text{ molecule}^{-1} \text{ s}^{-1}$, more than two times slower than the room-temperature value determined in this work ($k_1 = (2.2 \pm 0.3) \times 10^{-12} \text{ cm}^3 \text{ molecule}^{-1} \text{ s}^{-1}$). Information regarding the products was not given in that previous study, but Simonaitis and Heicklen³ proposed that vibrationally excited CH_3O formation in reaction 1a was the major channel (if not the exclusive channel) by which the $\text{CH}_3 + \text{O}_3$ reaction proceeds. The basis of this proposal was that the large preexponential factor obtained in the Arrhenius expression favors a linear transition state yielding CH_3O and O_2 .

Thermodynamically, the possibility exists that reaction 1 proceeds through different channels:



Other reaction pathways are

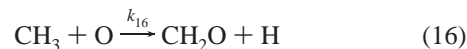


In the study of Washida et al.¹, methyl radicals were generated in the reaction of oxygen atoms with ethylene in a flow system

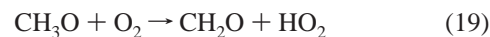
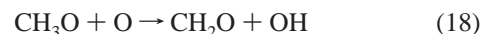
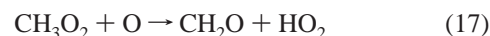


and the absolute rate constant for reaction 1 is obtained as a result of the competition among O, O_2 , and O_3 for CH_3 . Observing the effect of added O_3 on the steady-state concentra-

tion of CH_3 , they determined the ratio $k_1/k_{16} = 5.1 \times 10^{-3}$, where k_{16} refers to the reaction:



Using a value of $1.38 \times 10^{-10} \text{ cm}^3 \text{ molecule}^{-1} \text{ s}^{-1}$ for k_{16} , they calculated $k_1 = (7.0 \pm 2.7) \times 10^{-13} \text{ cm}^3 \text{ molecule}^{-1} \text{ s}^{-1}$ and found this to be independent of total pressure ($p_T = 2\text{--}6 \text{ Torr}$). This value is in fair agreement with that obtained by Simonaitis and Heicklen³ but is approximately three times slower than the value determined in this work. This pressure independence shows that the addition reaction channel (1e), if indeed it occurs, must be in the high-pressure limit under our experimental conditions ($p_T = 100 \text{ Torr}$). Washida et al.¹ did not detect formic acid, HCOOH , by mass spectrometry, although the ionization potential of this compound is smaller (11.05 eV) than that of the ionization source employed (11.83 and 11.62 eV). However, a large signal at $m/z = 30$ due to formaldehyde, CH_2O , was observed but cannot be assigned exclusively to reaction channel 1b because the presence of CH_2O could be due to the contribution of other reactions such as



On the other hand, Ogryzlo et al.² determined the rate constant k_1 at 2 Torr as a function of temperature ($T = 243\text{--}384 \text{ K}$) by monitoring CH_3 decay using photoionization mass spectrometry detection coupled to a flash photolysis system. The corrected rate constants for the pressure drop between the reaction cell and the capacitance manometer gave the following Arrhenius expression²⁹

$$k_1(T) = (5.1 \pm 1.6) \times 10^{-12} \exp((-210 \pm 84)/T) \text{ cm}^3 \text{ molecule}^{-1} \text{ s}^{-1} \quad (\text{V})$$

yielding a value of $k_1 = 2.5 \times 10^{-12} \text{ cm}^3 \text{ molecule}^{-1} \text{ s}^{-1}$ at room temperature. This value is in good agreement with that determined in this work. Information concerning the products of reaction 1 was not obtained in that kinetic study, and a signal was not observed at $m/z = 31$, corresponding to CH_3O radical, although the authors were not sure that this radical would be photoionized by the 123.6 nm radiation used.

The LIF detection of CH_3O radicals in this reaction, reported for the first time in this work, reveals that reaction channel 1a occurs only to a small extent.

5. Conclusions and Atmospheric Implications

In this paper, we present the first determination of the CH_3O yield in the reaction of CH_3 with O_3 at room temperature and 100 Torr of total pressure. The low branching ratio observed in this study, $\phi_{\text{CH}_3\text{O}} \cong 0.044$, can be explained by the formation of highly vibrationally excited CH_3O and the subsequent prompt dissociation to produce formaldehyde, CH_2O , and H atoms



but also by the direct formation of $\text{CH}_2\text{O} + \text{HO}_2$ in reaction channel 1b.

We also report the first direct measurement of the rate constant for the reaction $\text{CH}_3\text{O} + \text{O}_3$ at room temperature and

100 Torr. The value obtained using the system CH₃ONO($\lambda = 193$ nm)/O₃/He is $k_2(T = 298 \text{ K}) = (2.53 \pm 0.75) \times 10^{-14} \text{ cm}^3 \text{ molecule}^{-1} \text{ s}^{-1}$.

In polluted environments, the estimated tropospheric lifetime for the CH₃ radical in the presence of O₃ (150 ppbv) and NO₂ (30 ppbv) is less than 1 s. This value is estimated, taking into account the global rate constant for the CH₃ + O₃ reaction obtained in this work ($k_1 = 2.2 \times 10^{-11} \text{ cm}^3 \text{ molecule}^{-1} \text{ s}^{-1}$) and the rate constant of the reaction CH₃ + NO₂ + He at atmospheric pressure using the values of k_{3b}^0 and k_{3b}^∞ extracted in this work ($k_{3b} = 5.7 \times 10^{-11} \text{ cm}^3 \text{ molecule}^{-1} \text{ s}^{-1}$). In the natural atmosphere, the reaction of the CH₃ radical with O₃ (30 ppbv) dominates over the reaction with NO₂ (1 ppbv). However, due to the great abundance of O₂ ($5 \times 10^{18} \text{ molecule cm}^{-3}$), the major CH₃ removal process in the atmosphere is reaction 14.

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